Special Issue

Development of CMOS-MEMS/NEMS Devices

Message from the Guest Editors

Micro and nano-electro-mechanical system (M/NEMS) devices constitute key technological building blocks to enable increased additional functionalities within Integrated Circuits (ICs) in the More-Than-Moore era, as described in the International Technology Roadmap for Semiconductors. The CMOS ICs and M/NEMS dies can be combined in the same package (SiP), or integrated within a single chip (SoC). In the SoC approach the M/NEMS devices are monolithically integrated together with CMOS circuitry allowing the development of compact and low-cost CMOS-M/NEMS devices for multiple applications (physical sensors, chemical sensors, biosensors, actuators, energy actuators, filters, mechanical relays, and others). On-chip CMOS electronics integration can overcome limitations related to the extremely low-level signals in sub-micrometer and nanometer scale electromechanical transducers enabling novel breakthrough applications. This Special Issue aims to gather high quality research contributions dealing with MEMS and NEMS devices monolithically integrated with CMOS, independently of the final application and fabrication approach adopted (MEMSfirst, interleaved MEMS, MEMS-last or others).

Guest Editors

Dr. Jaume Verd

Electronic Systems Group (GSE), University of the Balearic Islands, E-07122 Palma, Spain

Prof. Dr. Jaume Segura

Electronic Systems Group (GSE), University of the Balearic Islands, E-07122 Palma (Illes Balears), Spain

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Micromachines
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
micromachines@mdpi.com

mdpi.com/journal/micromachines





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Editor-in-Chief

Prof. Dr. Ai-Qun Liu

- 1. Department of Electrical and Electronic Engineering, The Hong Kong Polytechnic University, Hong Kong, China
- 2. School of Electrical and Electronic Engineering, Nanyang Technological University, Singapore 639798, Singapore

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